



U.S. Department of Commerce, Patent and Trademark Office					Docket No.: 3816.09			
					Serial No.: 10/670,990			
LIST OF RELEVANT ART CITED BY APPLICANT					Applicant: James E. BOYLE			
(Use several sheets if necessary)					Filing Date: September 25, 2003			
					Group: 1733			
U.S. PATENT DOCUMENTS								
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
JUB	AA	6,239,004	05/29/01	Aga et al.	438	455		
JUB	AB	6,450,346	09/17/02	Boyle et al.	211	41.18	06/30/00	
JUB	AC	6,544,864	04/08/03	Reeder et al.	438	455	08/22/01	
	AD							
	AE							
	AF							
	AG							
	AH							
FOREIGN PATENT DOCUMENTS (Translation)								
		Document Number	Date	Country	Class	Subclass	Yes	No
	AL							
	AM							
	AN							
	AO							
	AP							
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)								
JUB	AR	Lowery et al., "Cutting large optics costs with planform bonding", <i>Photonics Spectra</i> , April 1992, pp. 159-161						
JUB	AS	Mark J. Loboda et al., "Understanding hydrogen silsesquioxane-based dielectric film processing", <i>Solid State Technology</i> , May 1998, pp. 1-4						
JUB	AT	"Nanotoxicity of nanomaterials?", <i>Chemistry</i> , Autumn 2003, p. 5						
Examiner Gayme L. Brown			Date Considered 7/7/05					
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.								

U.S. Department of Commerce, Patent and Trademark Office					Docket No.: 3816.09		
					Serial No.: 10/670,990		
LIST OF RELEVANT ART CITED BY APPLICANT					Applicant: James E. BOYLE		
(Use several sheets if necessary)					Filing Date: September 25, 2003		
					Group: 1733		

OIP
 MAR 08 2004
 U.S. DEPT. OF COMMERCE
 PATENT & TRADEMARK OFFICE

U.S. PATENT DOCUMENTS							
*Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
JUB	AA	6,239,004	05/29/01	Aga et al.	438	455	
	AB	6,450,346	09/17/02	Boyle et al.	211	41.18	06/30/00
JUB	AC	6,544,864	04/08/03	Reeder et al.	438	455	08/22/01
	AD						
	AE						
	AF						
	AG						
	AH						

FOREIGN PATENT DOCUMENTS (Translation)								
	Document Number	Date	Country	Class	Subclass	Yes	No	
	AL							
	AM							
	AN							
	AO							
	AP							

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)		
JUB	AR	Lowery et al., "Cutting large optics costs with planform bonding", <i>Photonics Spectra</i> , April 1992, pp. 159-161
	AS	Mark J. Loboda et al., "Understanding hydrogen silsesquioxane-based dielectric film processing", <i>Solid State Technology</i> , May 1998, pp. 1-4
JUB	AT	"Nanotoxicity of nanomaterials?", <i>Chemistry</i> , Autumn 2003, p. 5

Examiner Gayme L. Brown	Date Considered 7/7/05
-----------------------------------	----------------------------------

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.

U.S. Department of Commerce, Patent and Trademark Office					Docket No.: 3816.09			
					Serial No.: 10/670,990			
LIST OF RELEVANT ART CITED BY APPLICANT					Applicant: James E. BOYLE et al.			
(Use several sheets if necessary)					Filing Date: September 25, 2003			
					Group: 1733			
U.S. PATENT DOCUMENTS								
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date if Appropriate	
JUB	AA	6,004,866	12/21/99	Nakano et al.	438	459		
	AB	6,051,452	04/18/00	Shigyo et al.	438	151		
	AC	6,056,123	05/02/00	Niemirowski et al.	206	711		
	AD	6,099,302	08/08/00	Hong et al.	432	259		
JUB	AE	6,145,673	11/14/00	Burrows et al.	211	41.18		
	AF							
	AG							
	AH							
FOREIGN PATENT DOCUMENTS (Translation)								
		Document Number	Date	Country	Class	Subclass	Yes	No
	AL							
	AM							
	AN							
	AO							
	AP							
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)								
	AR							
	AS							
	AT							
Examiner		Date Considered						
Gayme L. Brown		7/7/05						
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.								

2931